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Organic Photonic Materials and Devices XIII

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Contents

vii *Conference Committee*

SESSION 1 NONLINEAR OPTICS

- 7935 02 **Optimization of organic NLO materials for integration with silicon photonic, plasmonic (metal optics), and metamaterial devices (Keynote Paper)** [7935-01]
L. R. Dalton, A. K.-Y. Jen, B. H. Robinson, R. Overney, S. J. Benight, D. B. Knorr, Jr., Univ. of Washington (United States); S. Kim, H. R. Fetterman, Univ. of California Los Angeles (United States); C. Zhang, Norfolk State Univ. (United States)

SESSION 2 ORGANIC LED

- 7935 09 **Hybrid organic light emitting device with silicon-rich oxide as hole transporting layer** [7935-08]
G. Z. Ran, D. F. Jiang, Y. Yin, W. J. Xu, Peking Univ. (China)

SESSION 3 ORGANIC LASER AND EMISSION

- 7935 0A **Towards highly-efficient liquid crystal microlasers (Invited Paper)** [7935-09]
F. Araoka, H. Takezoe, Tokyo Institute of Technology (Japan)
- 7935 0B **Characterization of fluorescence resonance energy transfer of a nanopatterned fluorophore doped polymer film fabricated using nanoimprint lithography** [7935-10]
R. Furukawa, The Univ. of Electro-Communications (Japan)
- 7935 0C **Energy transfer processes in a polymer laser** [7935-11]
K. H. Ibanouf, Imam Mohammed bin Saud Islamic d Univ. (Saudi Arabia); M. S. Alsalhi, V. Masilamani, Z. S. Abu Mustafa, King Saud Univ. (Saudi Arabia)
- 7935 0D **Laser from a liquid excimer** [7935-12]
M. Al Salhi, King Saud Univ. (Saudi Arabia); K. H. Ibanouf, Imam Mohammed bin Saud Islamic d Univ. (Saudi Arabia); V. Masilamani, King Saud Univ. (Saudi Arabia)
- 7935 0E **Preparation and characterization of DNA-aromatic surfactant complexes for optoelectronic applications** [7935-13]
T.-Y. Lin, C.-Y. Chang, C.-H. Lien, Y.-W. Chiu, W.-T. Hsu, C.-H. Su, Y.-S. Wang, Y.-C. Hung, National Tsing Hua Univ. (Taiwan)

SESSION 4 ORGANIC ELECTRONICS

- 7935 0G **Effect of intermolecular interactions on charge and exciplex formation in high-performance organic semiconductors** [7935-15]
W. E. B. Shepherd, A. D. Platt, G. Banton, D. Hofer, Oregon State Univ. (United States); M. A. Loth, J. E. Anthony, Univ. of Kentucky (United States); O. Ostroverkhova, Oregon State Univ. (United States)
- 7935 0H **Charge transport anisotropy in a pentacene transistor with an underlying photo-alignment layer** [7935-16]
T. Kawaguchi, T. Okura, Y. Kondo, I. Fujieda, Ritsumeikan Univ. (Japan)

SESSION 5 PHOTONIC TECHNOLOGIES

- 7935 0J **Photonic polymer research based on strategic promotion of innovative research and development supported by Japan Science and Technology Agency (Keynote Paper)** [7935-18]
S. Miyata, Tokyo Institute of Technology (Japan) and Japan Science and Technology Agency (Japan); N. Tsutsumi, Kyoto Institute of Technology (Japan); J. Watanabe, Tokyo Institute of Technology (Japan); T. Yatagai, Utsunomiya Univ. (Japan); O. Sugihara, Tohoku Univ. (Japan); K. Hakuta, The Univ. of Electro-Communications (Japan)
- 7935 0L **Template assisted polymerization of functional materials and their opto-electronic properties** [7935-20]
J. Kim, Yonsei Univ. (Korea, Republic of); C. Anand, National Institute for Materials Science (Japan); J. You, Y. Kim, B. Kim, Yonsei Univ. (Korea, Republic of); A. Vinu, National Institute for Materials Science (Japan); E. Kim, Yonsei Univ. (Korea, Republic of)
- 7935 0M **Fabrication and characterization of PDMS thin film** [7935-21]
S. Wang, A. Kallur, Univ. of North Texas (United States); A. Goshu, Total Wire Corp. (United States)

SESSION 6 NANO PHOTONICS

- 7935 0P **Effects of surface chemistry and shape on nonlinear absorption, scattering, and refraction of PbSe nanocrystals** [7935-24]
I. L. Bolofin, D. J. Asunskis, A. M. Jawaid, Y. Liu, P. T. Snee, L. Hanley, Univ. of Illinois at Chicago (United States)

SESSION 7 NONLINEAR ABSORPTION

- 7935 OS **Multifunctional hybrid nanoparticles for two-photon fluorescence imaging and photodynamic therapy (Invited Paper)** [7935-28]
P. L. Baldeck, Lab. Interdisciplinaire de Physique, CNRS, Univ. Joseph Fourier (France) and Lab. de Chimie, CNRS, Univ. de Lyon 1 (France); M. Maurin, Lab. Interdisciplinaire de Physique, CNRS, Univ. Joseph Fourier (France); C. Philipot, Institut Néel, CNRS, Univ. Joseph Fourier (France); S. Zaiba, Lab. Interdisciplinaire de Physique, CNRS, Univ. Joseph Fourier (France) and Univ. M'hamed Bouguera (Algeria); T. Gallavardin, O. Maury, C. Andraud, Lab. de Chimie, CNRS, Univ. de Lyon 1 (France); F. Dubois, A. Ibanez, Institut Néel, CNRS, Univ. Joseph Fourier (France); F. Lerouge, S. Parola, Lab. de Chimie, CNRS, Univ. de Lyon 1 (France); O. Stephan, Lab. Interdisciplinaire de Physique, CNRS, Univ. Joseph Fourier (France); B. van Der Sanden, INSERM (France)

SESSION 8 NEW MATERIALS AND METHODS

- 7935 OT **New developments in molecular photonics: from photoswitchable nonlinearities to nonlinear nanoplasmonics (Keynote Paper)** [7935-30]
I. Ledoux-Rak, K. Hoang-Thi, Anu, J. Zyss, Ecole Normale Supérieure de Cachan (France)
- 7935 OU **Ferromagnetism in pristine polythiophene at low temperature (Invited Paper)** [7935-31]
P. Gangopadhyay, The Univ. of Arizona (United States); G. Koeckelberghs, Katholieke Univ. Leuven (Belgium); A. Persoons, The Univ. of Arizona (United States)
- 7935 OV **Chirality in molecular films at the air-water interface** [7935-32]
E. Benichou, G. Gassin-Martin, A. Derouet, I. Russier-Antoine, G. Bachelier, C. Jonin, N. Lascoux, Lab. de Spectrométrie Ionique et Moléculaire, CNRS, Univ. Claude Bernard Lyon 1 (France); M. Liu, Beijing National Lab. for Molecular Sciences (China); P.-F. Brevet, Lab. de Spectrométrie Ionique et Moléculaire, CNRS, Univ. Claude Bernard Lyon 1 (France)

SESSION 9 APPLICATIONS

- 7935 OY **Switching mechanism of an optically-gated optical switch using an organic dye** [7935-35]
T. Hiraga, I. Ueno, National Institute of Advanced Industrial Science and Technology (Japan); N. Shiga, Trimatiz Ltd. (Japan); H. Watanabe, S. Futaki, Inter Energy Co., Ltd. (Japan); M. Kubo, Himeji Rika Co., Ltd. (Japan); S. Takarada, N. Tanaka, Dainichiseika Color & Chemicals Mfg. Co., Ltd. (Japan)
- 7935 OZ **Enhanced laser induced polarization switching and holography using a dynamic holographic network recording system** [7935-36]
Q. Sun, P. Wu, New Span Opto-Technology Inc. (United States); S. Baig, H. Lu, M. R. Wang, Univ. of Miami (United States)
- 7935 10 **Optical data storage in photochromic compounds** [7935-37]
W. Dallari, Italian Institute of Technology (Italy) and Univ. of Genoa (Italy); M. Scotto d'Abbusco, E. Samoylova, F. Pignatelli, A. Athanassiou, R. Cingolani, Italian Institute of Technology (Italy); A. Diaspro, Italian Institute of Technology (Italy) and Univ. of Genoa (Italy); M. Allione, Italian Institute of Technology (Italy)

POSTER SESSION

- 7935 15 **Improvement in viewing angle properties of top-emitting organic light-emitting devices**
[7935-42]
B.-T. Liou, Hsiuping Institute of Technology (Taiwan); M.-C. Tsai, Y.-H. Huang, F.-M. Chen,
Y.-R. Lin, Y.-K. Kuo, National Changhua Univ. of Education (Taiwan)
- 7935 16 **Photopatterning and electro-optical switching of redox active fluorescent polymers**
[7935-43]
S. Seo, Y. Kim, J. You, T. Park, E. Kim, Yonsei Univ. (Korea, Republic of)
- 7935 17 **Ultrafast nonlinear optical properties and excited state dynamics of phthalocyanine thin
films** [7935-44]
S. Venugopal Rao, P.T. Anusha, T. S. Prashant, D. Swain, S. P. Tewari, Univ. of Hyderabad
(India)
- 7935 18 **Synthesis and characterization of thiophene-based conjugated copolymer containing
ferroceneunits for organic electronics** [7935-45]
S. Kim, Y. Kim, X. Yang, K. Kim, W. Kim, E. Kim, Yonsei Univ. (Korea, Republic of)

Author Index

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(United States)
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(Japan)
Shiyoshi Yokoyama, Kyushu University (Japan)

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- 1 Nonlinear Optics
Robert L. Nelson, Air Force Research Laboratory (United States)
- 2 Organic LED
Robert L. Nelson, Air Force Research Laboratory (United States)
- 3 Organic Laser and Emission
Chantal Andraud, Ecole Normale Supérieure de Lyon (France)
- 4 Organic Electronics
Jang-Joo Kim, Seoul National University (Korea, Republic of)
- 5 Photonic Technologies
Yasuhiro Koike, Keio University (Japan)
- 6 Nano Photonics
Toshikuni Kaino, Tohoku University (Japan)
- 7 Nonlinear Absorption
Kwang-Sup Lee, Hannam University (Korea, Republic of)
- 8 New Materials and Methods
François Kajzar, Université d'Angers (France)
- 9 Applications
André P. Persoons, Katholieke Universiteit Leuven (Belgium)